## IN THE CLAIMS

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Claims 2-9 are pending in this application. Please cancel claims 1 and 18-19 without prejudice or disclaimer, and amend claims 2-9, as follows:

- 1. (Canceled)
- 2. (Currently Amended) A method of manufacturing a solid-state image sensing device according to claim 1, comprising the steps of:
  - (a) preparing a wiring substrate mother board having a first face and a second face on the side opposite to said first face;
  - (b) mounting first electronic components over said first face of said wiring substrate mother board;
    - (c) encapsulating said first electronic components by using an encapsulation body;
    - (d) mounting second electronic components including image sensors over
    - said second face of said wiring substrate mother board; and
  - (e) joining a frame to said second face of said wiring substrate mother board so as to cover said second electronic components,

wherein said frame has a position adjustment pin for adjusting the position of said frame with said wiring substrate mother board.

wherein said wiring substrate mother board has a through hole into which said position adjustment pin is to be inserted, and

wherein said position adjustment pin and said through hole are provided outside a junction face between said frame and said wiring substrate mother board,

wherein said step (e) includes a sub-step of selectively coating a junction face of said frame with a bonding agent through a mask, and said sub-step of selectively coating a junction face of said frame with a bonding agent is carried out in such a way that said position adjustment pin of said frame is not coated with said bonding agent.

3. (Currently Amended) [[A]]The method of manufacturing a solid-state image sensing device according to claim [[1]]2, wherein in said step (c), said encapsulation body is formed in such a way that said through hole of said wiring substrate mother board is avoided.

4. (Currently Amended) [[A]]<u>The</u> method of manufacturing a solid-state image sensing device according to claim [[1]]2,

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wherein said wiring substrate mother board has a plurality of module regions,

wherein said encapsulation body used in said step (c) is a batch encapsulation body for encapsulating said first electronic components in said module regions in the aggregate, and

wherein in said step (c), said batch encapsulation body is formed in such a way that said through hole of said wiring substrate mother board is avoided.

- 5. (Currently Amended) [[A]]The method of manufacturing a solid-state image sensing device according to claim 4, wherein in said step (c), a plurality of said batch encapsulation bodies is formed over said first face of said wiring substrate mother board with said batch encapsulation bodies being separated from each other.
- 6. (Currently Amended) [[A]]<u>The</u> method of manufacturing a solid-state image sensing device according to claim 5, wherein a depression is formed in a portion of each of said batch encapsulation bodies.
- 7. (Currently Amended) [[A]]The method of manufacturing a solid-state image sensing device according to claim 4, wherein in said step (c), said module regions are divided into a plurality of groups and a plurality of said first electronic components in each of said groups is encapsulated in the aggregate.
- 8. (Currently Amended) [[A]]The method of manufacturing a solid-state image sensing device according to claim 7, wherein in said step (c), an encapsulation material is supplied to any particular one of said groups through an encapsulation-material-supplying path provided for said particular one of said groups so as to form said encapsulated body for said particular one of said groups in the aggregate.
- 9. (Currently Amended) [[A]]<u>The</u> method of manufacturing a solid-state image sensing device according to claim [[1]]<u>2</u>, wherein said image sensors are each a CMOS image sensor.

10. (Withdrawn) A method of manufacturing a solid-state image sensing device comprising the steps of:

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- (a) preparing a wiring substrate mother board having a first face and a second face on the side opposite to said first face;
- (b) mounting first electronic components over said first face of said wiring substrate mother board;
  - (c) encapsulating said first electronic components by using an encapsulation body;
- (d) mounting second electronic components including image sensors over said second face of said wiring substrate mother board; and
- (e) joining a frame to said second face of said wiring substrate mother board so as to cover said second electronic components,

wherein said frame has a position adjustment pin for adjusting the position of said frame with respect to said wiring substrate mother board,

wherein said wiring substrate mother board has a through hole into which said position adjustment pin is to be inserted, and

wherein in said step (c), said encapsulation body is formed in such a way that said through hole is avoided.

- 11. (Withdrawn) A method of manufacturing a solid-state image sensing device according to claim 10,
  - wherein said wiring substrate mother board has a plurality of module regions, and said step (c) is a step of forming said encapsulation body as a batch encapsulation body for encapsulating said first electronic components in said module regions in the aggregate.
- 12. (Withdrawn) A method of manufacturing a solid-state image sensing device according to claim 11, wherein a plurality of said batch encapsulation bodies is formed over said first face of said wiring substrate parent substrate with said batch encapsulation bodies being separated from each other.
- 13. (Withdrawn) A method of manufacturing a solid-state image sensing device according to claim 12, wherein a depression is formed in a portion of each of said batch encapsulation bodies.

14. (Withdrawn) A method of manufacturing a solid-state image sensing device according to claim 11, wherein in said step (c), said module regions are divided into a plurality of groups and a plurality of said first electronic components in each of said groups is encapsulated in the aggregate.

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- 15. (Withdrawn) A method of manufacturing a solid-state image sensing device according to claim 14, wherein in said step (c), an encapsulation material is supplied to any particular one of said groups through an encapsulation-material-supplying path provided for said particular one of said groups so as to form said encapsulated body for said particular one of said groups in the aggregate.
- 16. (Withdrawn) A method of manufacturing a solid-state image sensing device comprising the steps of:
  - (a) preparing a wiring substrate mother board having a first face and a second face on the side opposite to said first face;
  - (b) mounting first electronic components over said first face of said wiring substrate mother board;
    - (c) encapsulating said first electronic components by using an encapsulation body;
  - (d) mounting second electronic components including image sensors over said second face of said wiring substrate mother board;
  - (e) joining a frame to said second face of said wiring substrate mother board so as to cover said second electronic components;
  - (f) cutting out individual module regions from said wiring substrate mother board obtained as a result of said step (e); and
  - (g) mounting a lens holder housing optical lens to said frame in each of said individual module regions obtained as a result of said step (f),

wherein said wiring substrate mother board has a plurality of said module regions, wherein said frame has a position adjustment pin for adjusting the position of said frame with respect to said wiring substrate mother board,

said wiring substrate mother board has a through hole into which said position adjustment pin is to be inserted;

wherein said position adjustment pin and said through hole are provided outside a junction face between said frame and said wiring substrate mother board,

wherein said encapsulation body used in said step (c) is a batch encapsulation body for encapsulating said first electronic components in said module regions in the aggregate, and

wherein a plurality of said batch encapsulation bodies is formed over said wiring substrate mother board with said batch encapsulation bodies separated from each other to avoid said through hole.

17. (Withdrawn) A method of manufacturing a solid-state image sensing device according to claim 16, wherein said image sensors are each a CMOS image sensor.

18-19. (Canceled)